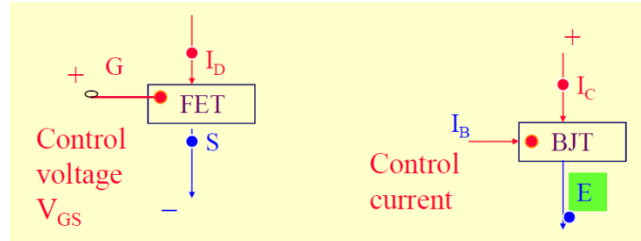


## BEC JFET 01

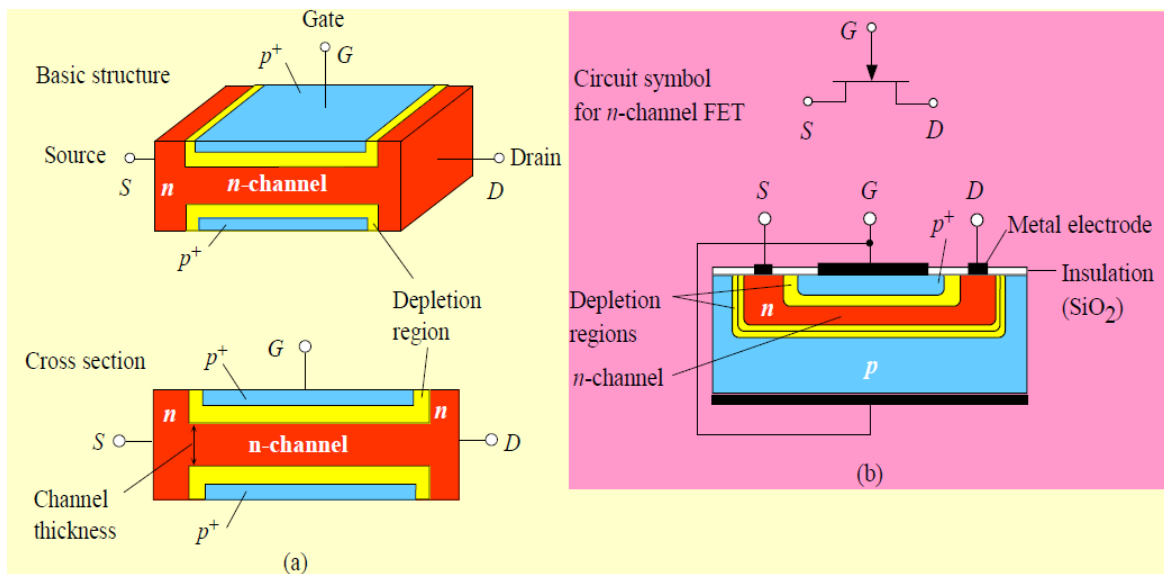
**Topics Covered: JFET comparison with BJT, JFET construction, working, region of operation, transfer and output characteristics, Shockley's equation, Observations from output and transfer characteristics, JFET parameters, and Numericals based on JFET's Shockley's equation**

### BJT Vs JFET



- The conventional bipolar transistor has two type of current carriers of both polarities (majority and minority) and FET has only one type of current carriers, p or n (holes or electrons)
- The BJT is current controlled and FET is voltage controlled current between two other terminals
- **JFET is a high-input resistance device**, while the BJT is comparatively low.
- **JFET junction is reverse-biased, the gate current is practically zero, and a very high impedance at input** whereas the base current of the BJT is always some value greater than zero, for example, in  $\mu\text{As}$

**Field effect transistor is a unipolar-transistor, which acts as a voltage-controlled current device and is a device in which the current is controlled and transported by carriers of one polarity (majority) only and an electric field near the one terminal controls the current between other two.**



**(a) The basic structure of the junction field effect transistor (JFET) with an n-channel. The two  $p^+$  regions are electrically connected and form the gate. (b) A simplified sketch of the cross section of a more practical n-channel JFET.**

## JFET CONCEPTS

## 9.1

### 9.1.1 Basic *pn* JFET Operation

The first type of field-effect transistor is the *pn* junction field-effect transistor, or *pn* JFET. A simplified cross section of a symmetrical device is shown in Fig. 9.2. The *n*-region between the two *p*-regions is known as the channel and, in this *n*-channel device, majority carrier electrons flow between the source and drain terminals. The source is the terminal from which carriers enter the channel from the external circuit, the drain is the terminal where carriers leave, or are drained from, the device, and the gate is the control terminal. Two gate terminals shown in Fig. 9.2 are tied together to form a single gate connection. Since majority carrier electrons are primarily involved in the conduction in this *n*-channel transistor, the JFET is a majority-carrier device or an unipolar device.

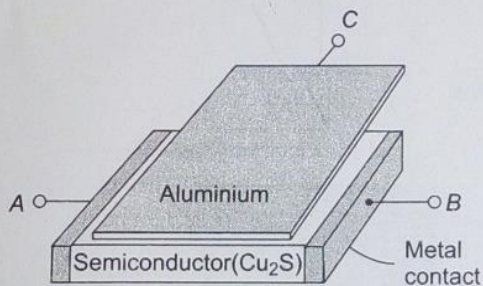


Fig. 9.1 Idealization of the Lilienfeld transistor (From Pierret [10])

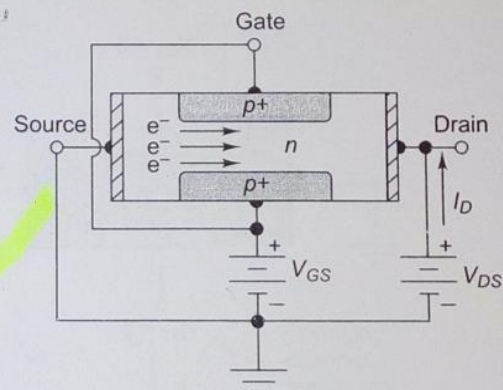


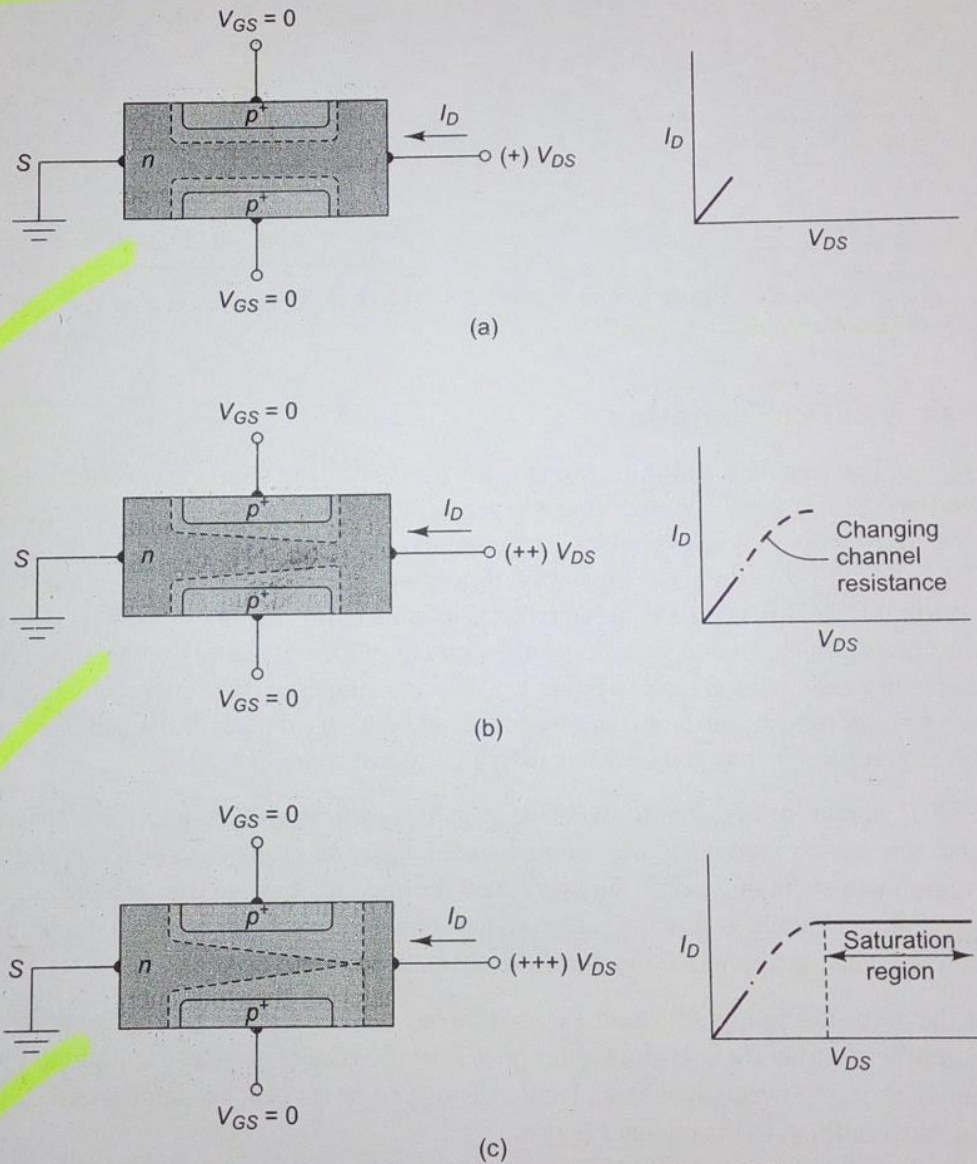
Fig. 9.2 Cross section of a symmetrical *n*-channel *pn* junction FET

A complementary *p*-channel JFET can also be fabricated in which the *p*- and *n*-regions are reversed from those of the *n*-channel device. Holes will flow in the *p*-type channel between source and drain and the source terminal will now be the source of the holes. The current direction and voltage polarities in the *p*-channel JFET are the reverse of those in the *n*-channel device. The *p*-channel JFET is generally a lower frequency device than the *n*-channel JFET due to the lower hole mobility.

Figure 9.3(a) shows an *n*-channel *pn* JFET with zero volts applied to the gate. If the source is at ground potential, and if a small positive drain voltage is applied, a drain current  $I_D$  is produced between the source and drain terminals. The *n* channel is essentially a resistance so the  $I_D$  versus  $V_{DS}$  characteristic, for small  $V_{DS}$  values, is approximately linear, as shown in the figure.

When we apply a voltage to the gate of a *pn* JFET with respect to the source and drain, we alter the channel conductance. If a negative voltage is applied to the gate of the *n*-channel *pn* JFET shown in Fig. 9.3, the gate-to-channel *pn* junction becomes reverse biased. The space charge region now widens so the channel region becomes narrower and the resistance of the *n* channel increases. The slope of the  $I_D$  versus  $V_{DS}$  curve, for small  $V_{DS}$ , decreases. These effects are shown in Fig. 9.3(b). If a larger negative gate voltage is applied, the condition shown in Fig. 9.3(c) can be achieved. The reverse-biased gate-to-channel space charge region has completely filled the channel region. This condition is known as *pinch-off*. The drain current at pinch-off is essentially zero, since the depletion region isolates the source and drain terminals. Figure 9.3(c) shows the  $I_D$  versus  $V_{DS}$  curve for this case, as well as the other two cases.

If the drain voltage increases further, the condition shown in Fig. 9.4(c) can result. The channel has been pinched off at the drain terminal. Any further increase in drain voltage will not cause an increase in drain current. The  $I-V$  characteristic for this condition is also shown in this figure. The drain voltage at pinchoff is referred to as  $V_{DS}(\text{sat})$ . For  $V_{DS} > V_{DS}(\text{sat})$ , the transistor is said to be in the saturation region and the drain current, for this ideal case, is independent of  $V_{DS}$ . At first glance, we might expect the drain current to go to zero when the channel becomes pinched off at the drain terminal, but we will show why this does not happen.



**Fig. 9.4** Gate-to-channel space charge regions and  $I-V$  characteristics for zero gate voltage and for (a) a small drain voltage, (b) a larger drain voltage, and (c) a drain voltage to achieve pinchoff at the drain terminal

Figure 9.5 shows an expanded view of the pinchoff region in the channel. The  $n$ -channel and drain terminal are now separated by a space charge region which has a length  $\Delta L$ . The electrons move through the  $n$ -channel from the source and are injected into the space charge region where, subjected to the  $E$ -field force, they are swept through into the drain contact area. If we assume that  $\Delta L \ll L$ , then the electric field in the  $n$ -channel

region remains unchanged from the  $V_{DS}(\text{sat})$  case; the drain current will remain constant as  $V_{DS}$  changes. Once the carriers are in the drain region, the drain current will be independent of  $V_{DS}$ ; thus, the device looks like a constant current source.

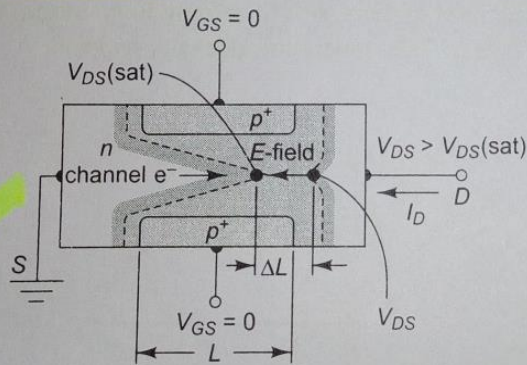


Fig. 9.5 Expanded view of the space charge region in the channel for  $V_{DS} > V_{DS}(\text{sat})$

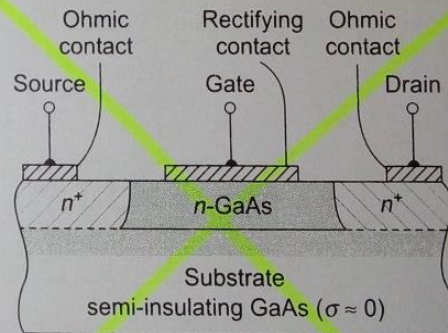
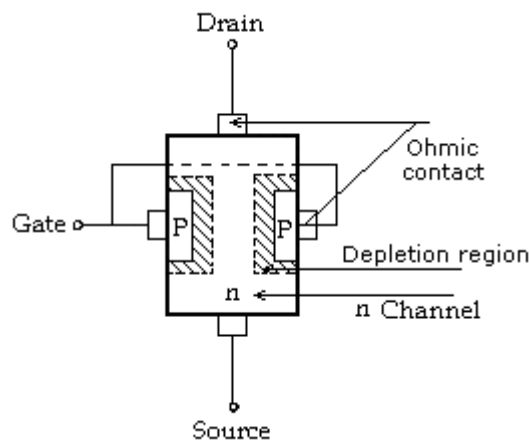


Fig. 9.6 Cross section of an n-channel MESFET with a semi-insulating substrate

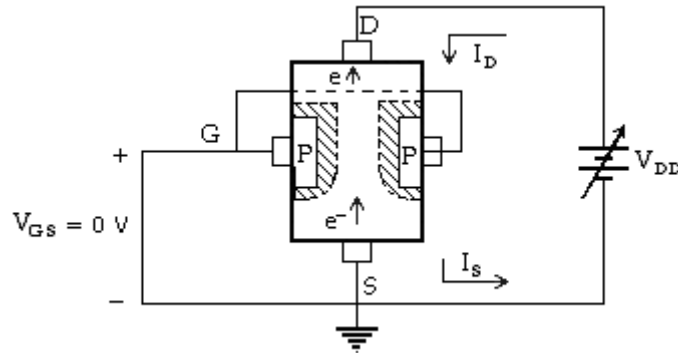
### Construction & Characteristics of n-channel JFET:-



The basic construction of n-channel FET is as shown in figure. The major part of JEET is the channel between embedded P type of material. The top of the n-channel is connected to an ohmic contact called as 'Drain' (D) & Lower end of Channel is called as 'Source' (S). The two p types of materials are connected together & to the 'Gate' terminal (G).

### Working and Characteristic:-

#### 1. $V_{GS} = 0V$ , $V_{DS}$ - Some +ve Value:-



As shown in the figure the gate is directly connected to source to achieve  $V_{GS} = 0V$ , this is similar to no bias condition. The instant the voltage  $V_{DD}(=V_{DS})$  is applied, the  $e^-$  will be drawn to the drain terminal, causing  $I_D$  &  $I_S$  to flow (i.e.  $I_D = I_S$ ). Under this condition the flow of charge is limited solely by resistance of the n channel between drain & source.

It is important to note that the depletion region wider at the top of both p type of material. Since the upper terminal is more R.B. than the lower terminal (source - S).

As voltage  $V_{DS}$  is increased from 0 to few volts, the current will increase as determined by ohm's law. If still  $V_{DS}$  is increased & approaches a level referred as  $V_p$ , the depletion region will widen, causing a noticeable reduction in channel width. The reduced path of conduction causes the resistance to increase. The more the horizontal curve, the higher resistance.

If  $V_{DS}$  is increase to a level where it appears that the two depletion region would touch each other, the condition referred as 'pinch -off' will result. The level of  $V_{DS}$  that establish this condition is called as 'pinch off voltage' ( $V_p$ ). At  $V_p$ ,  $I_D$  should be zero, but practically a small channel still exists & very high density current still flows through the channel.

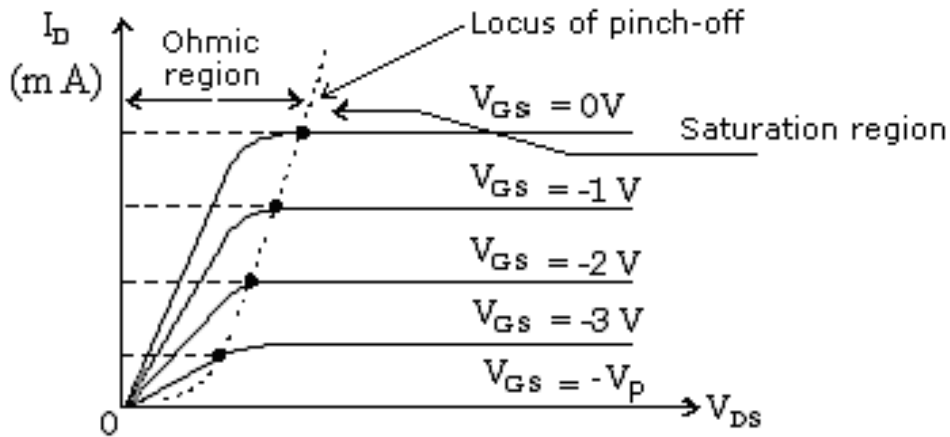
As  $V_{DS}$  is increased beyond  $V_p$  the saturation current will flow through the channel ( $I_{DSS}$ ).

$I_{DSS}$  – Drain to source saturation current from source to Gate.

**2.  $V_{GS} < 0V$ :-**

If a -ve bias is applied between gate and source, the effect of the applied -ve bias  $V_{GS}$  is to establish depletion region similar to those obtained with  $V_{GS} = 0V$  but at lower level of  $V_{DS}$ .

As  $V_{GS}$  will become more & more -ve biased, the depletion layer pinch off occur at the less & less value of  $V_{DS}$ . Eventually, when  $V_{GS} = -V_P$ , will be sufficiently -ve to establish a saturation level, i.e. essentially 0 mA & for all practical purpose the device has been 'turned OFF.'



The region to the right of the pinch – off locus is typically employed in linear amplifiers (Amplifier with min. distortion at applied signal) is commonly referred as the constant current, saturation or linear amplification region.

**Voltage controlled region.** :-The region left of pinch – off locus is called as ohmic or voltage controlled region. In this region the JEET can actually be employed as a variable register whose resistance is controlled by  $V_{GS}$ . As  $V_{GS}$  becomes more & more -ve, the slope of the curve becomes more & more horizontal, corresponding with an increasing resistance level.

$$r_d = \frac{r_o}{\left(1 - \frac{V_{GS}}{V_P}\right)^2}$$

where,

$r_o$  – the resistance with  $V_{GS} = 0V$

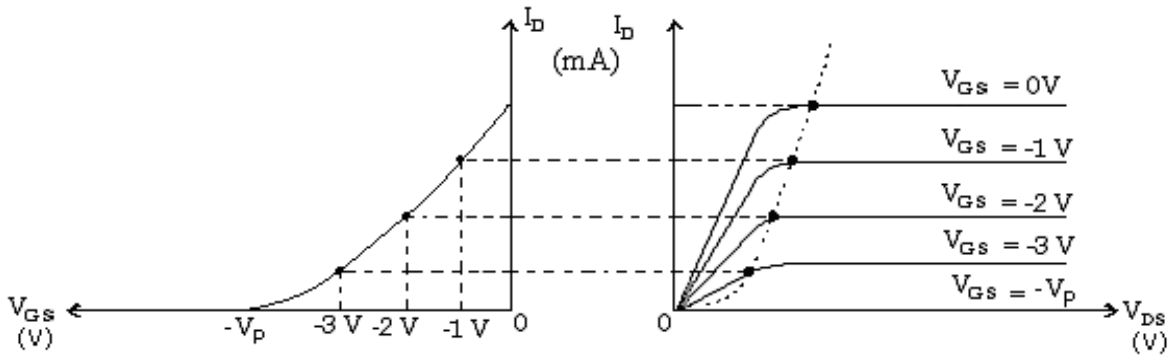
$r_d$  – the resistance at particular value of  $V_{GS}$ .

**Transfer characteristic:-**

The relation between  $I_D$  &  $V_{GS}$ , is given by Shockley's equation.

$$I_D = I_{DSS} \left( 1 - \frac{V_{GS}}{V_P} \right)^2$$

The squared term of equation will result in a non – linear relationship between  $I_D$  &  $V_{GS}$ .



**3.3.2 Transfer Characteristic**

It is the graph of gate to source voltage  $V_{GS}$  and drain current  $I_D$ . The transfer characteristic can be derived from the drain curve characteristic by plotting values of  $I_D$  for the value of  $V_{GS}$  taken from the family of drain curves in the pinch-off region as shown in Fig. 3.6. Each point on the transfer characteristic curve corresponds to specific values of  $V_{GS}$  and  $I_D$  on the drain curves. The transfer characteristic curve is nearly parabolic in shape and can therefore be expressed as,

$$I_D = I_{DSS} \left( 1 - \frac{V_{GS}}{V_P} \right)^2$$

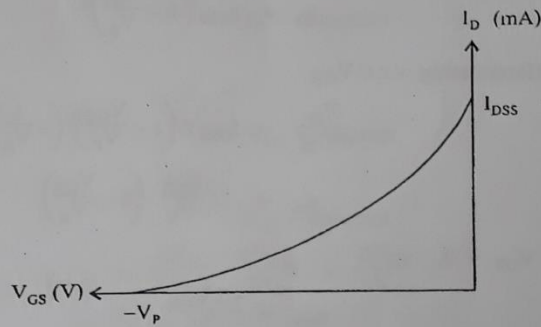


Fig. 3.6

**3.4 JFET PARAMETERS**

**3.4.1 Transconductance ( $g_m$ )**

It is the ratio of change in drain current to the change in gate source voltage at constant drain to source voltage.

$$g_m = \left. \frac{\Delta I_D}{\Delta V_{GS}} \right|_{V_{DS} = \text{constant}}$$

It is slope of transfer characteristic.

### Expression for $g_m$

We know that

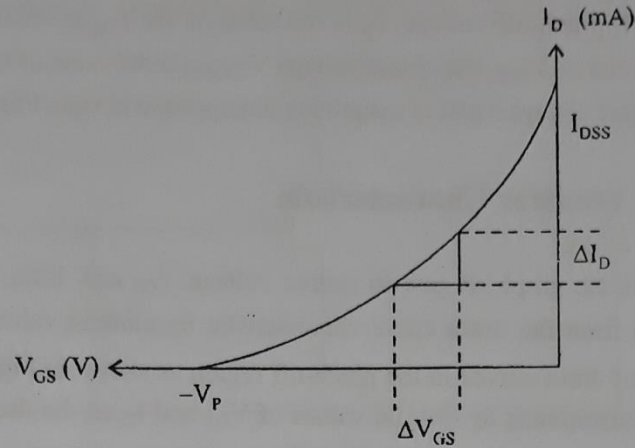


Fig. 3.7

$$I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_p}\right)^2$$

Differentiating w.r.t.  $V_{GS}$ ,

$$\frac{\partial I_D}{\partial V_{GS}} = I_{DSS} 2 \left(1 - \frac{V_{GS}}{V_p}\right) \left(-\frac{1}{V_p}\right)$$

$$g_m = -2 \frac{I_{DSS}}{V_p} \left(1 - \frac{V_{GS}}{V_p}\right)$$

If  $V_{GS} = 0$ ,

$$g_{m0} = \frac{-2 I_{DSS}}{V_p}$$

$$g_{m0} = \frac{2 I_{DSS}}{|V_p|}$$

$$g_m = g_{m0} \left(1 - \frac{V_{GS}}{V_p}\right) = \frac{2 I_{DSS}}{|V_p|} \sqrt{\frac{I_D}{I_{DSS}}}$$

where  $g_{m0}$  is maximum value of transconductance.

A large change in  $V_{GS}$  causes small change in  $I_D$ . Hence  $g_m$  is very small.

### 3.4.2 Drain resistance ( $r_d$ )

It is the ratio of change in drain source voltage to the change in drain current at constant gate source voltage

$$r_d = \left. \frac{\Delta V_{DS}}{\Delta I_D} \right|_{V_{GS} = \text{constant}}$$



It is reciprocal of the slope of drain source characteristics

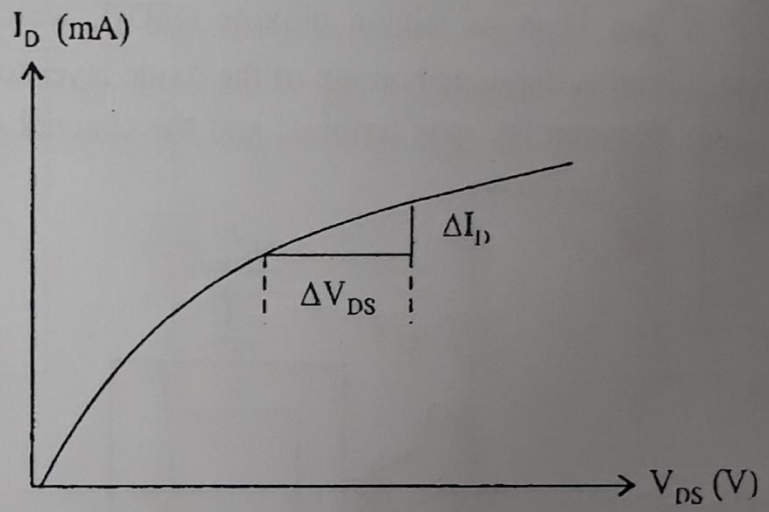


Fig. 3.8

# JFET

01  
18/8/17

## Numerical 01

A n-channel JFET has a drain current of 5mA. If  $I_{DSS} = 10\text{mA}$  and  $V_{GS(0bb)} = -6\text{V}$ . Find value of  
a)  $V_{GS}$  (Gate to source voltage)  
b)  $V_p$

Sol<sup>n</sup>:- a)  $I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_{GS(0bb)}}\right)^2$

$$5\text{mA} = 10\text{mA} \left(1 + \frac{V_{GS}}{6}\right)^2$$

$$\frac{1}{2} = \left(1 + \frac{V_{GS}}{6}\right)^2$$

ie  $1 + \frac{V_{GS}}{6} = \frac{1}{\sqrt{2}} = 0.707$

ie  $V_{GS} = -1.757\text{V}$

b)  $V_p = |V_{GS(0bb)}| = 6\text{V}$

## Numerical 02

02

The datasheet of an nJFET gives the following information: -

$$I_{DSS} = 7 \text{ mA}, V_{GS(0ff)} = -2.5 \text{ V}$$

- Find a)  $g_m$  (transconductance) for  $V_{GS} = -1.5 \text{ V}$   
b) Drain current at this point

Sol<sup>n</sup>:- a) 
$$g_m = -\frac{2I_{DSS}}{V_{GS(0ff)}} \left(1 - \frac{V_{GS}}{V_{GS(0ff)}}\right)$$
$$= \frac{-2 \times 7 \times 10^{-3}}{-2.5} \left(1 - \frac{(-1.5)}{(-2.5)}\right)$$

$$g_m = 2.24 \frac{\text{mA}}{\text{V}}$$

b) 
$$I_D = I_{DSS} \left(1 - \frac{V_{GS}}{V_{GS(0ff)}}\right)^2 = 7 \text{ mA} \left(1 - \frac{(-1.5)}{(-2.5)}\right)^2$$

$$I_D = 1.12 \text{ mA}$$